

Practical work

01 - FIB-SEM nano-tomography for materials science

Pierre-Henri Jouneau UGA, CEA Grenoble, IRIG / MEM /LEMMA

Dual-beam microscopes which combine a field-emission scanning electron column (SEM) and a focused ion beam (FIB) are becoming a standard tool in nanotechnology research and in industry. Here, the FIB allows the machining of an object with an accuracy of a few nm whilst the SEM allows its visualization at nm scale.

It is commonly used for prototyping and fabrication of nano-devices such as MEMS, photonic arrays or AFM tips. In the semiconductor industry, this is now the standard tool for the preparation of thin (<100 nm) lamella for TEM observations,

Another emerging application of this instrument is the 3D imaging of nanostructures by "slice and view" imaging: a sample is cut slice by slice with the FIB, and each fresh surface is imaged in 2D using the SEM. This technique is robust and versatile: it can be applied to visualize 3D semiconducting or metallic nanostructures, and it is revolutionizing the way biological ultra-structures are imaged in life sciences [1].



(a) Zeiss XB 550 dual-beam microscope used in this practical. (b) Nano-porosity revealed in a Cu-Cu direct bonding after annealing. (c) Structure of a C/Si battery anode.

This practical will demonstrate how FIB-SEM nano-tomography can be used to image 3D nano-devices. This will be done on the new Zeiss XB550 microscope installed recently at the PFNC (Plateforme de NanoCaracterisation @ Miatec). We will also discusses the various tools that subsequently allow the extraction of quantitative information from the image stack, and how to visualize them in 3D.

 M. Cantoni, L. Holzer, Advances in 3D focused ion beam tomography, MRS bulletin 39 (2014) 354